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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
09/997,244	11/30/2001	Satoshi Mashima	900-409	3534
75	11/04/2002			
NIXON & VANDERHYE P.C. 8th Floor 1100 North Glebe Road			EXAMINER	
			ALEJANDRO MULERO, LUZ L	
Arlington, VA 22201			ART UNIT	PAPER NUMBER
			1763	

Please find below and/or attached an Office communication concerning this application or proceeding.

, .	Application No.	Applicant(s)				
	09/997,244	MASHIMA ET AL.				
Office Action Summary	Examiner	Art Unit				
	Luz L. Alejandro	1/63				
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply						
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, - Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).  Status	36(a). In no event, however, may a reply be time within the statutory minimum of thirty (30) days will apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE	rely filed s will be considered timely. the mailing date of this communication. O (35 U.S.C. § 133).				
1) Responsive to communication(s) filed on 24 C	October 2002 .					
2a)☐ This action is <b>FINAL</b> . 2b)ဩ Thi	is action is non-final.					
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.						
Disposition of Claims  ANGL Claim(a) 1 and 2 in/are pending in the application	:					
4) Claim(s) 1 and 2 is/are pending in the application.						
4a) Of the above claim(s) is/are withdrawn from consideration.  5) Claim(s) is/are allowed.						
6)[☑ Claim(s) <u>1 and 2</u> is/are rejected. 7)☐ Claim(s) is/are objected to.						
8) Claim(s) are subject to restriction and/or	coloction requirement					
Application Papers	election requirement.					
9) The specification is objected to by the Examiner	· ·					
10) The drawing(s) filed on is/are: a) accep		niner.				
Applicant may not request that any objection to the	drawing(s) be held in abeyance. Se	ee 37 CFR 1.85(a).				
11)☐ The proposed drawing correction filed on is: a)☐ approved b)☐ disapproved by the Examiner.						
If approved, corrected drawings are required in reply to this Office action.						
12) The oath or declaration is objected to by the Examiner.						
Priority under 35 U.S.C. §§ 119 and 120						
13) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).						
a) All b) Some * c) None of:						
1. Certified copies of the priority documents have been received.						
2. Certified copies of the priority documents have been received in Application No						
<ul> <li>3. Copies of the certified copies of the priori</li> <li>application from the International Bur</li> <li>See the attached detailed Office action for a list of</li> </ul>	eau (PCT Rule 17.2(a)).	_				
14)☐ Acknowledgment is made of a claim for domestic	·					
a) ☐ The translation of the foreign language prov 15)☐ Acknowledgment is made of a claim for domestic	visional application has been rece	eived.				
Attachment(s)	. ,					
1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449) Paper No(s) 4	( - )	(PTO-413) Paper No(s) atent Application (PTO-152)				

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## **DETAILED ACTION**

## Election/Restrictions

Applicant's election of group I in Paper No. 6 is acknowledged. Because applicant did not distinctly and specifically point out the supposed errors in the restriction requirement, the election has been treated as an election without traverse (MPEP § 818.03(a)).

## Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35 U.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).

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Claims 1-2 are rejected under 35 U.S.C. 103(a) as being unpatentable over Moustakas et al., U.S. Patent 4,407,710 in view of Shinichi, JP 07-183227 (machine translation provided).

Moustakas et al. shows the invention substantially as claimed including a solar cell production method comprising the steps of: forming a first electrode layer 11 on a substrate 10; forming a n-layer 12, an intrinsic layer 14 by glow discharge, and a p-layer 14, where the p and n layer can be reversed (see col. 2-line 66 to col. 4-line 32, col. 4-line 68 to col. 5-line 4 and fig. 1), and forming a second electrode layer 18 on the n-layer (see col. 4-lines 46-48).

Moustakas et al. fails to expressly disclose wherein the intrinsic layer is formed by a plasma CVD method employing plasma discharge caused by application of a pulse-modulated high frequency voltage having a pulse ON time of not longer than 50 microseconds and a duty ratio of not higher than 50% or, more specifically, wherein the pulse ON time is not longer than 10 microseconds and the duty ratio is not higher than 20%. Shinichi discloses a method of forming a silicon layer through plasma CVD employing plasma discharge caused by application of a pulse-modulated high frequency voltage, where the ON time has a duty ratio of approximately 10-15% (see paragraph 0017 of translation under detailed description). In view of this disclosure, it would have been obvious to one of ordinary skill in the art at the time the invention was made to form the intrinsic silicon of Moustakas et al. using the process disclosed by Shinichi because this forms a film of uniform thickness and quality due to the reduction of plasma interference within the chamber (see abstract). With respect to the pulse ON

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time, Moustakas et al. discloses a pulse width of approximately 150 microseconds.

However, it would have been obvious to determine through routine experimentation the

optimum pulse ON time in order to maintain the duty ratio disclosed in Shinichi based

upon, for instance, the desired thickness of the film and such a limitation would not lend

patentability to the instant invention absent the showing of unexpected results.

Conclusion

Any inquiry concerning this communication or earlier communications from the

examiner should be directed to Luz L. Alejandro whose telephone number is 703-305-

4545. The examiner can normally be reached on Monday to Thursday from 7:30 to

6:00.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Gregory L. Mills can be reached on 703-308-1633. The fax phone numbers

for the organization where this application or proceeding is assigned are 703-872-9310

for regular communications and 703-872-9311 for After Final communications.

Any inquiry of a general nature or relating to the status of this application or

proceeding should be directed to the receptionist whose telephone number is 703-308-

0661.

Patent Examiner

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October 31, 2002

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